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## THE OPEN UNIVRVERSITY OF SRI LANKA B.Sc DEGREE PROGRAMME / STAND ALONE COURSE 2004 / 2005

## LEVEL 4 - FINAL EXAMINATION

432

CHU 2221 / CHE 4221 - ORGANIC CHEMISTRY - PAPER I

Duration: 21/2 HOURS	

Attempt as many questions as possible.  Maximum marks allocated to this paper are 120. However a candidate who scores marks or above will be awarded 100% and those scoring less will be awarded the sthey make.  Write your answers in the space provided at each question.  1. Answer both parts.  (a) State whether each of the following compounds will form hydrogen bonds and themselves. (Strike off the incorrect answer).  CH <sub>3</sub> CO <sub>2</sub> H CH <sub>3</sub> CHO CHCl <sub>3</sub> CH <sub>3</sub> CO <sub>2</sub> C <sub>2</sub> H <sub>5</sub> Yes/No Yes/No Yes/No Yes/No (2 Ma (b) State, which compound has the higher solubility in water in each of the following pairs of compounds.  i. o-nitrophenol and p-nitrophenol  ii. propanol and propanal		Duration: 2 <sup>1</sup> / <sub>2</sub>	HOURS	
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they make.  Write your answers in the space provided at each question.  1. Answer both parts.  (a) State whether each of the following compounds will form hydrogen bonds among themselves. (Strike off the incorrect answer).  CH <sub>3</sub> CO <sub>2</sub> H CH <sub>3</sub> CHO CHCl <sub>3</sub> CH <sub>3</sub> CO <sub>2</sub> C <sub>2</sub> H <sub>5</sub> Yes/No Yes/No Yes/No Yes/No Yes/No (2 Ma)  (b) State, which compound has the higher solubility in water in each of the following pairs of compounds.  i. o-nitrophenol and p-nitrophenol  ii. propanol and propanal  (2 Ma)  CH <sub>3</sub> CH=CHCH <sub>3</sub>	Attempt as many questions	s as possible.		
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CH <sub>3</sub> CO <sub>2</sub> H CH <sub>3</sub> CHO CHCl <sub>3</sub> CH <sub>3</sub> CO <sub>2</sub> C <sub>2</sub> H <sub>5</sub> Yes/No Yes/No Yes/No Yes/No (2 Ma  (b) State, which compound has the higher solubility in water in each of the following pairs of compounds.  i. o-nitrophenol and p-nitrophenol  ii. propanol and propanal  (2 Mai)  CH <sub>3</sub> CH=CHCH <sub>3</sub>	1. Answer both parts.			
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(2 Ma (b) State, which compound has the higher solubility in water in each of the following pairs of compounds.  i. o-nitrophenol and p-nitrophenol ii. propanol and propanal  (2 Mar (3 CH3CH=CHCH3))	CH₃CO₂H	CH₃CHO	CHCl <sub>3</sub>	CH₃CO₂C₂H₅
(b) State, which compound has the higher solubility in water in each of the following pairs of compounds.  i. o-nitrophenol and p-nitrophenol ii. propanol and propanal  (2 Mai)  Give the structures of A and B of the following reaction scheme.	Yes/No	Yes/No	Yes/No	Yes/No
ii. propanol and propanal  (2 Mai  Give the structures of A and B of the following reaction scheme.	(b) State, which compoun-	pound has the higher so ds.	olubility in water in e	(2 Marks
+- CH <sub>3</sub> CH=CHCH <sub>3</sub>				(2 Marks
	2. Give the structures of A a	and <b>B</b> of the following	reaction scheme.	
АВ	K OEt + CHCI3 —	A	CH <sub>3</sub> CH=CHCH <sub>3</sub>	В

(4 Marks)

3.	How would you explain the fact that 2-butene is more	e stable t	nan 1-0	utene.	
		. **			
			•	•	
					(4 Marks
4.	Give a chemical test to distinguish between the comp	oounds ir	each o	f the foll	owing pairs
	of examples.				
	(a) Et and O		\$		
		•••••			•••••
·	$\begin{array}{cccccccccccccccccccccccccccccccccccc$				:
		*********	•••••		(4 Mark
5	6. Giving the mechanism postulate the structure of the when 2-methyl propane is heated with a limited amount	mono-h ount of E	alogena Ir <sub>2</sub> to a l	ted prodi igher ter	act formed mperature.
			<i>i</i> .		

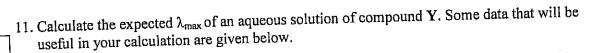
6. Give the structure of the products of the following reactions with their stereochem	istry.
$\begin{array}{c ccccccccccccccccccccccccccccccccccc$	Marks)
7. Complete the following reaction scheme giving structures of the reactants.	IVIGI KS)
1. Mg / dry ether 2. \( \frac{2}{3}. \) H+ / H <sub>2</sub> O (4	Marks)
8. Give the major products of the following two reactions.	
i. Na OCH₂CH₃ + (CH₃)₃CBr →	
ii. CH₃CH₂CI + (CH₃)₃CŌ K →	
	Marks)
9. Give the structures of the products A and B of the following reaction.	
O CMe <sub>3</sub> CF <sub>3</sub> CO <sub>2</sub> H A B	
	Aarks)
10. Explain how KMnO <sub>4</sub> dissolves in benzene in the presence of 18-crown-6.	

(4 Marks)

[arks)

airs

ks)



Base value for a six membered ring enone  $= 215 \, \text{nm}$ Base value for a five membered ring enone = 202 nmIncrements for =30 nmdouble bond extending conjugation = 10 nmalkyl group or ring residue at a = 12 nm= 18 nmγ and higher 5 nm exocyclic double bond =39 nmhomoannular diene component = 00 nmSolvent correction for ethanol = - 8 nm Solvent correction for water

(4 Marks)

12. A is an aliphatic compound and contains C, H, O and N only. A shows peaks at 1735 cm<sup>-1</sup> and 2200 cm<sup>-1</sup> but no peaks above 3000 cm<sup>-1</sup>. Assign the two peaks to functional groups you would expect to be present in A.

IR peak	Functional group
1735 cm <sup>-1</sup>	
2200 cm <sup>-1</sup>	

(4 Marks)

13. Mass spectrum of compound show a molecular ion peak at m/z = 45. The compound does not contain oxygen. Deduce what element other than C and H are present in the compound?

(2 Marks)

vill be

14. The approximate δ values of the resonance signals (peaks) of the compound X are 8.2,
7.2, 3.6, 2.4 and 0.8 ppm. Assign the signals to the hydrogen atoms in X by labelling them as A, B etc. Draw the <sup>1</sup>H NMR spectrum of the compound showing multiplicities of the signals in the box provided.

(5 Marks)

15. When benzene is placed in a magnetic field (H<sub>O</sub>) a ring current is created which induces a magnetic field (H).

(a) In the figure shown below draw the ring current and draw the secondary magnetic field generated by the ring current.

(b) Indicate by an equation how the protons outside the ring are deshielded.

16. Explain the following observation.

(5 Marks)

ı (Å)
<u> </u>
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**********************
(3 Marks)

rks)

m<sup>-I</sup>

ks)

ies

cs)

184601

17. Draw the $\pi$ molecular or	hital diagram of evelor	octatetraene and deter	mine whether i	t is
17. Draw the $\pi$ molecular or aromatic or not.	Jital diagram of Systoc			\$
cyclooctatetraene			Ì	
				: : :
		·	(	6 Marks)
18. Give the structure of th	e product of the follow	ving reaction.		
+ 0				(2 Marks)
19. Give the structures of	•	lowing reactions.		(4 Marks)
CH₃CH₂CH₂CN	1. ( <sup>i</sup> Bu) <sub>2</sub> AIH / -78 °C 2. H <sub>2</sub> O			(3 Marks)
20. Arrange the following	ng acids in the order of	increasing acidity.		
BrCH₂CO₂H	CH₃CH₂CO₂H	CH₃CO₂H	CICH₂CO₂H	
Α	В	<b>C</b> .	<b>D</b>	
······································	<	<		(2 Mark

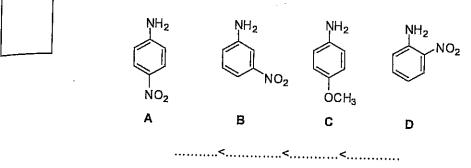
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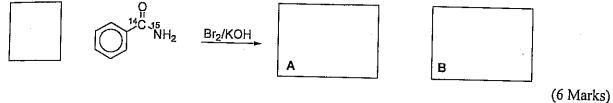
irks)

21. Arrange the following amines in the order of increasing p $K_b$  values.



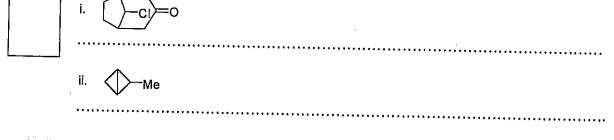
(3 Marks)

22. Predict the structures of the products  $\bf A$  and  $\bf B$  in the following reaction. Indicate the position of labelling in the products.



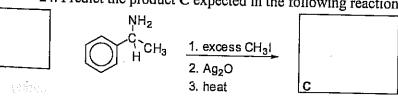
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23. Give the IUPAC names of the following compounds.



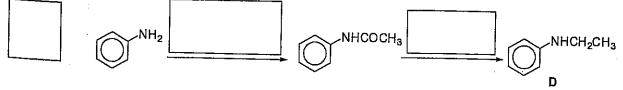
(4 Marks)

24. Predict the product C expected in the following reactions.



(3 Marks)

25. (i) Give the reagents required to effect the following reactions.



(ii) Will the product obtained by treating  $\underline{\mathbf{D}}$  with p-toluene sulphonyl chloride dissolve in KOH

rks)

(4 Marks)

26. Draw resonance structures to show t electrophiles ortho/para positions of	hat chlorine atom of chlorobenzene directs f benzene ring.
electrophiles of morphila positions	· ·
	(4 Marks)
27. (i) Indicate the product(s) expected	in the following reaction
· ·	
, och₃	
+ CO + HCI CuCl	/ AICl <sub>3</sub>
+ CO + HCJ	$\overline{\Delta}$
(ii) The reactant E required for the	above reaction is produced in the reaction mixture by the the structure of the compound E.
reaction of HCI and CO. Give	TO SECURITION SECURITION TO SECURITION SECURITIO
	(4 Marks)
	t 0-5 °C to give a product <u>F</u> which reacts with excess
28. Aniline reacts with NaNO <sub>2</sub> / HCl a	ow coloured compound G. Draw the structure of G.
N,N-dimethylaniline to give a year	OW odiourou observa
	(A) 1.3
	(4 Marks)
29. Give the reagents required to effe	ct the following reaction sequence.
Br	
	(4.3.5-yles
_	(4 Marks
	Indicate the product formed in
30. Give the mechanism involved in	the following reaction. Indicate the product formed in
the reaction	
Ο Δ	,
	·
	(4 Mark
	· · · · · · · · · · · · · · · · · · ·
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